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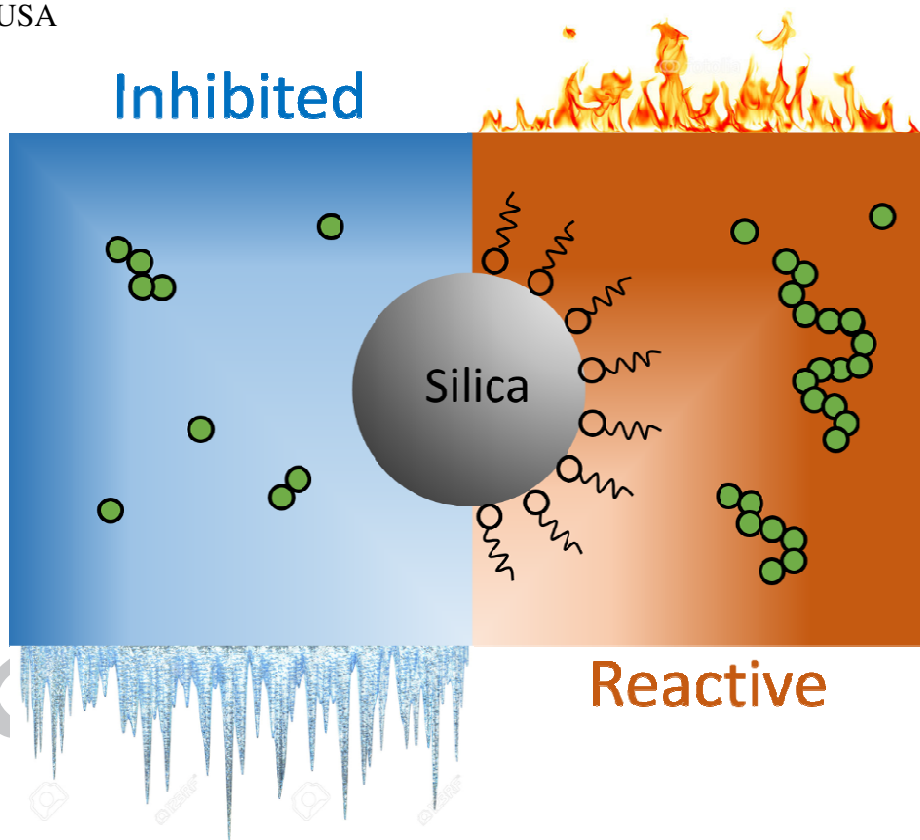
Cationic Surfactant Blocks Radical-Inhibiting Sites on Silica

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